## Adding Phosphorus to Hypereutectic Silicon-Aluminum Using 8% Phosphorus-Copper

Phosphorus has been shown to be an effective nucleant for primary Silicon in hypereutectic Silicon-Aluminum alloys (Si >12%). The addition of Phosphorus to Aluminum is difficult because it:

- Is highly volatile at the temperature of the bath.
- Oxidizes readily at the metal surface.
- Forms a less dense AIP compound that separates to the surface dross.

A successful method of adding Phosphorus to Aluminum is to add pre-alloyed Phosphorus-Copper compounds.

Phosphorus-Copper is commercially produced in two compositions, 8% P-Cu and 15% P-Cu. Above 15%, Phosphorus is insoluble in Copper. At 15% P, the alloy is nearly 100% Cu<sub>3</sub>P, the most concentrated form of Phosphorus in Copper. At 8% P, the alloy forms an eutectic (lowest melting composition) mixture of Copper with Cu<sub>3</sub>P. Both Phosphorus-Copper compositions are manufactured as shot, usually to a controlled size.

Consider the reactions necessary to refine the primary Silicon crystals in hypereutectic Silicon-Aluminum. The Cu<sub>3</sub>P must react with Aluminum such that

 $Cu_3P + AI \longrightarrow AIP + 3Cu$ .

The Copper must be dissolved and alloyed with the Aluminum. The Phosphorus must be won away from the Copper compound (Cu<sub>3</sub>P) and the raw compound AIP must be formed.

- The AIP formation is highly exothermic, and the particles of AIP would be hotter than the bath surrounding them.
- 2. The AIP, being less dense, tends to float to the surface.
- At the surface, the AIP readily reacts with air to form Aluminum Oxide and Phosphorus Pentoxide.
   The addition of 15% P-Cu will aggravate these three negative

influences of the AIP formation in the bath. By using 8% P-Cu, the amount of local Phosphorus at the reaction/dissolution site is reduced, hence the superheat and the volume of AIP formed is reduced. The buoyant tendency of AIP may be overcome by surface tension phenomenon and the nucleant will reside in the bath longer.

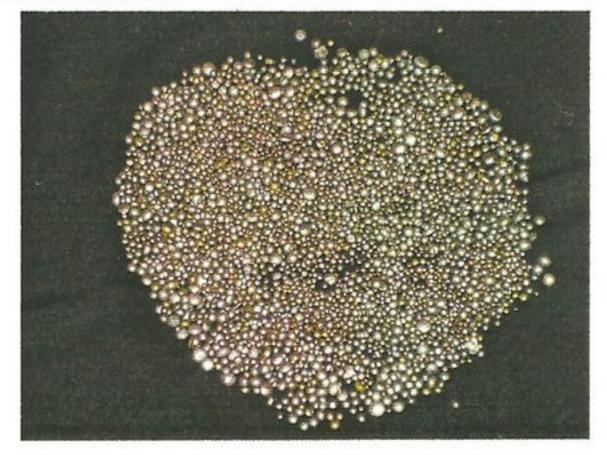
By reducing the particle size of the 8% P-Cu, there is further reduction in the local Phosphorus concentration at the reaction/dissolution site. Thus, the above exothermicity and density factors are mollified. Using a (3/8" x 1/16") shot size is far better than a coarser material. Because 15% P-Cu has a higher Phosphorus concentration than 8% P-Cu, it will more readily react with moisture and air to form a complex Copper-Phosphorus-Oxygen coating on the shot surface. This coating contains hydrated P₂O₅ and CuO and entraps moisture as well. The combination of hydrated oxides makes 15% P-Cu more difficult to react with Aluminum to successfully produce AIP nuclei.

In conclusion, Milward Alloys recommends inoculating hypereutectic Silicon-Aluminum alloys with

8% Phosphorus-Copper (3/8" x 1/16") shot

## because:

- 8% P-Cu is more compatible with the local Aluminum reaction dissolution than 15% P-Cu.
- 2. Less of the AIP formed is floated to the surface and lost.
- The dispersion and distribution of the AIP formed with the 8% P-Cu is more compatible with the needs of nucleation in the Silicon-Aluminum alloy.
- 4. The surface integrity of 8% P-Cu is superior to 15% P-Cu for reaction dissolution in Aluminum.





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